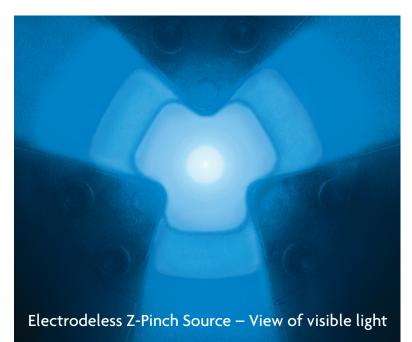
# EQ-10HR High Repetition Rate EUV Light Source



### Electrodeless Z-Pinch<sup>™</sup>10 kHz EUV Source

The EQ-10HR is a compact, easy-to-use, reliable, and cost-effective EUV light source based on Energetiq's proven Electrodeless Z-Pinch<sup>™</sup> technology using Xenon gas. The EQ-10HR high repetition rate EUV source is uniquely suited for metrology and research applications where simulation of high volume manufacturing (HVM) is required.

The Energetiq EQ-10HR EUV source is a stand-alone system, ready to be integrated into a process tool. It includes the electrodeless Z-pinch source assembly, maglev vacuum pumping subsystem, gas delivery subsystem, power delivery subsystem, and control electronics.



### Features and Benefits

- Performance
  - 10 kHz pulse rate
  - Small plasma size
  - Low debris
- Low Cost of Ownership
  - Low Xenon flow rate
  - Minimized consumable cost
  - Small footprint
- Proven Reliability
  - Patented Electrodeless Z-Pinch™ technology
  - CE Mark and SEMI S2-0703 compliant

#### Applications

- Accelerated EUV Optics Testing
- EUV Metrology
- EUV Resist Development
- Defect Inspection
- EUV Microscopy

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## Electrodeless Z-Pinch<sup>™</sup> Technology

Z-pinch plasmas have been shown to be effective at producing EUV and SXR light. However, all the implementations to date have involved conducting high discharge currents into the plasma using electrodes. These electrodes, which are typically in contact with high temperature plasma, can melt and produce significant debris.

Energetiq's unique technology is also based on a Z-pinch plasma, but it avoids electrodes entirely by inductively coupling the current into the plasma. The plasma in the Energetiq source is magnetically confined away from the source walls, minimizing the heat load and reducing debris. Energetiq's Electrodeless Z-Pinch<sup>™</sup> technology has excellent spatial stability, and stable repeatable power output.

### **Specifications**

<b>EUV Performance</b> • Pulse Repetition Rate • Source Operating Pressure • Xenon Flow Rate	10 kHz 150 mTorr typical 100 sccm typical	
Physical Specifications EQ-10HR		
<ul> <li>Source Rack</li> <li>Instrument Rack</li> <li>Modulator</li> <li>Source</li> <li>Fore Pump Assembly</li> </ul>	<b>System Dimensions (H x W x D)</b> 2002 x 611 x 915 mm (78.8 x 24.1 x 36.0 in) 1356 x 611 x 915 mm (53.4 x 24.1 x 36.0 in) 498 x 356 x 701 mm (19.6 x 14.0 x 27.6 in) 810 x 697 x 769 mm (31.9 x 27.5 x 30.3 in) 643 x 259 x 460 mm (30.1 x 21.9 x 21.0 in)	Weight 440 kg (968 lbs) 215.5 kg (475 lbs) 54.4 kg (120 lbs) 98.4 kg (217 lbs) 27.7 kg (61 lbs)
Utility Requirements <ul> <li>Electrical</li> <li>Cooling Water</li> <li>Clean Dry Air</li> <li>Xenon</li> </ul>	208V, 3Ø, 50/60 Hz, 30A 40-60 PSID (0.28–0.41 MPa), 1.5 GPM (5.7 lpm) min., 30°C max. inlet 80–100 PSIG (0.55–0.69 MPa) 15–40 PSIG (0.10–0.28 MPa), 100 sccm max. (40 sccm typ.)	
Compliance • EQ-10 Series	CE Mark, SEMI S2-0703	

Patent Numbers: US 7,307,375; US 7,199,384; US 7,183,717; US 7,948,185; US 8,143,790; EP 2187711; Other patents applied for.

### About Energetiq

Energetiq Technology, Inc. is a developer and manufacturer of advanced light sources that enable the analysis and manufacturer of nano-scale structures and products. The Energetiq team combines its deep understanding of the high power plasma physics needed for high-brightness light generation with its long experience in building rugged industrial & scientific products. The result is that users can expect the highest levels of performance combined with the highest reliability.



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